



P/1250-251

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

New York, New York

Tatsufumi KUSUDA

Date: September 5, 2003

Serial No.: 10/621,429

Group Art Unit:

Filed: July 17, 2003

Examiner:

For: THERMAL PROCESSING APPARATUS FOR SUBSTRATE EMPLOYING
PHOTOIRRADIATION

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Respectfully submitted,

Max Moskowitz
Name of applicant, assignee or
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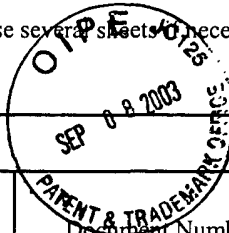
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September 5, 2003
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Enclosures

APPLICANT'S ART CITATION (Use several sheets if necessary)		Application 10/621,429		OFGS File No. P/1250-251	
		Applicant Tatsufumi KUSUDA, et al.			
		Filing Date 7/17/03		Group Art Unit	



U.S. PATENT DOCUMENTS						
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-4,525,380	06-1985	Arai, et al.			
	US-4,958,061	09-1990	Wakabayashi, et al.			
	US-4,567,352	01-1986	Mimura, et al.			
	US-					
	US-					

FOREIGN PATENT DOCUMENTS							
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
	02-077119	1990	Japan				X
	63-166219	1988	Japan				X
	59-169125	1984	Japan				X
	02-005294	1990	Japan				X
			Japan				X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)		
		English translation of portion of Japanese Patent Application Laid-Open No. 63-166219
		relevant to the instant application

Examiner	Date Considered
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.